

Surface-electrode ion trap with integrated light source

Tony Hyun Kim,^{1, a)} Peter F. Herskind,¹ and Isaac L. Chuang¹

Center for Ultracold Atoms, Department of Physics, Massachusetts Institute of Technology
77 Massachusetts Avenue, Cambridge, MA 02139

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An atomic ion is trapped at the tip of a single-mode optical fiber in a cryogenic (8 K) surface-electrode ion trap. The fiber serves as an integrated source of laser light, which drives the quadrupole qubit transition of the $^{88}\text{Sr}^+$. Through *in situ* translation of the nodal point of the trapping field, the Gaussian beam profile of the fiber output is imaged, and the fiber-ion displacement, in units of the mode waist at the ion, is optimized to within 0.13 ± 0.10 of the mode center despite an initial offset of 3.30 ± 0.10 . Fiber-induced charging at $125 \mu\text{W}$ is observed to be $\sim 10 \text{ V/m}$ at an ion height of $670 \mu\text{m}$, with charging and discharging time constants of $1.6 \pm 0.3 \text{ s}$ and $4.7 \pm 0.6 \text{ s}$ respectively. This work is of importance to large-scale, ion-based quantum information processing, where optics integration in surface-electrode designs may be a crucial enabling technology.

An array of trapped ions in optical cavities, connected by a network of optical fibers, represents a possible distributed architecture for large-scale quantum information processing¹ (QIP). Due to the necessity of efficient light collection, laser cooling and qubit state manipulation, the realization of a quantum network or processor at the level of tens and hundreds of qubits strongly motivates the integration of optics in surface-electrode ion traps². However, the potential benefits of integrated optics have long been overshadowed by the challenge of trapping ions in the proximity of dielectrics³, as well as the difficulty of guaranteeing good spatial overlap of the trapped ion with the field mode of the integrated element.

In the past, there have been demonstrations of integration of bulk mirrors⁴⁻⁶ and phase-Fresnel lenses⁷ into radio frequency (RF) traps with three-dimensional electrodes. More recently, integration of multi-mode optical fibers⁸ and microscopic reflective optics⁹ for collection of ion fluorescence has been demonstrated in microfabricated surface-electrode traps. Complementing such efforts on light collection, the present work demonstrates light delivery through an integrated single-mode (SM) fiber in a scalable, surface-electrode design, and an *in situ* micrometer-scale positioning of the ion relative to the integrated structure. Future developments in optics integration, such as microcavities for the realization of quantum light-matter interfaces¹, or lensed fibers for faster gate times and optical trapping of ions¹⁰, will employ sub- $10 \mu\text{m}$ waists⁹, underscoring the importance of *in situ* ion positioning¹¹.

We report on the construction of a fiber-trap system, and demonstrate the ability of the integrated light source to drive the 674 nm quadrupole transition of $^{88}\text{Sr}^+$. The quadrupole transition is of particular interest in QIP with trapped ions, where it serves as the optical qubit¹², as well as in metrology, where it constitutes an optical frequency standard¹³. The ion-fiber spatial overlap is optimized *in situ* by micromotion-free translation of the ion

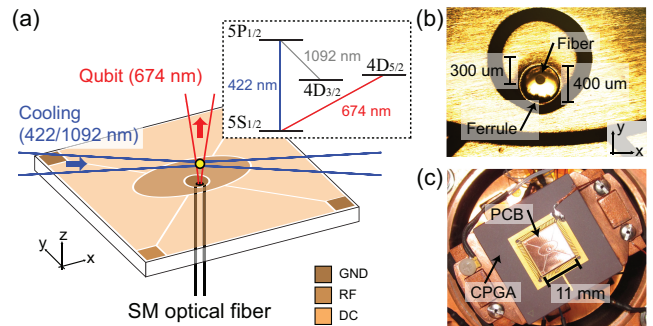


FIG. 1. (Color online) (a) Schematic of the surface-electrode ion trap with integrated optical fiber. The $^{88}\text{Sr}^+$ qubit laser is delivered axially (along z) through the fiber, while Doppler cooling beams propagate in the horizontal xy -plane. (b) Alignment of the optical ferrule with respect to the trap electrodes. The ferrule is rotated until the fiber is aligned with the minor (y) axis of the trap. (c) Fiber-trap system mounted on a CPGA and installed on the 8 K basplate of a closed-cycle cryostat.

using segmented RF electrodes. We use this technique to map out the Gaussian profile of the fiber mode along a single transverse axis. With the ion positioned over the peak of the mode, we quantify the magnitude and timescale of fiber-induced charging.

Fiber-trap integration is achieved by embedding the fiber within the trap substrate. Fig. 1(a) shows a schematic of the ion trap design, which is a modified version of the surface-electrode point Paul trap described recently¹⁴. The center, grounded electrode has a diameter of 1.1 mm . The elliptical RF pad has major- and minor-axis diameters of 5.9 mm and 2.8 mm , respectively, and is shifted by $500 \mu\text{m}$ along the minor-axis relative to the center of the ground electrode. Electrode gaps are $100 \mu\text{m}$. This design achieves an ion height of $670 \mu\text{m}$ and the electrode asymmetries uniquely define the principal axes of the trap, which are tilted by 30° in the yz -plane for efficient cooling and micromotion compensation. The side electrodes are used for DC compensation of stray

^{a)}Electronic mail: kimt@mit.edu

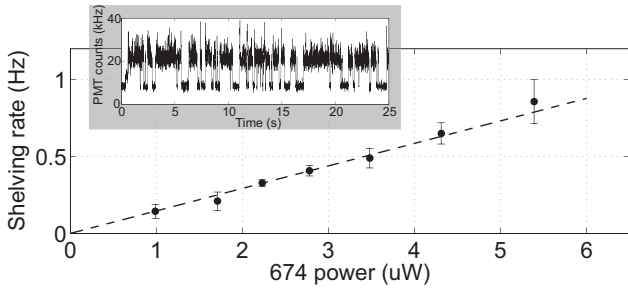


FIG. 2. Shelving rate as a function of 674 nm power coupled to the trap fiber. Inset: telegraph log of a single trapped ion as it is shelved into the dark $4D_{5/2}$ state by the fiber light.

electric fields, as well as radial translation of the RF node by use of additional RF voltages. The trap is defined on a printed circuit board (PCB) with copper electrodes on a low-RF-loss substrate (Rogers 4350B, fabricated by Hughes circuits). The PCB includes a $400\ \mu\text{m}$ -diameter plated via in the center ground electrode for the insertion of an optical ferrule. The via is offset by $300\ \mu\text{m}$ with respect to the ground electrode to account for the displacement of the trapping point that accompanies the shift of the elliptical RF electrode.

The optical fiber (OZ Optics, PMF-633-4/125-3-L) is SM for 674 nm and is conventionally prepared (i.e. cured in fiber epoxy and polished) in a stainless steel SMA ferrule whose tip has been machined to match the $400\ \mu\text{m}$ -diameter of the PCB via. The assembly of PCB and ferrule is performed under microscope, as in Fig. 1(b), where machining imprecision of the ferrule is evident in the form of $\sim 100\ \mu\text{m}$ nonconcentricity between the fiber and the ferrule. The ferrule is rotated with respect to the PCB to place the fiber roughly along the minor axis of the trap, and is cured using cyanoacrylate adhesive.

The fiber-trap system is installed on a ceramic pin grid array (CPGA) and mounted on the 8 K baseplate of a closed-cycle cryostat¹⁵ as shown in Fig. 1(c). The fiber is routed through a hole in the CPGA and a hole in a flange of the vacuum chamber, where it is sealed in place with TorrSeal UHV epoxy. The trap is operated at a typical RF frequency of $2\pi \times 6\ \text{MHz}$ and $250\ \text{Vpp}$ amplitude, achieving secular frequencies of $\omega_{z'} = 2\pi \times 410\ \text{kHz}$, $\omega_x = 2\pi \times 240\ \text{kHz}$, $\omega_{y'} = 2\pi \times 170\ \text{kHz}$. We produce $^{88}\text{Sr}^+$ ions by resonant photoionization¹⁶, which are Doppler cooled on the $5S_{1/2} \leftrightarrow 5P_{1/2}$ transition at 422 nm, while simultaneously driving the $4D_{3/2} \leftrightarrow 5P_{1/2}$ transition at 1092 nm. Ion fluorescence at 422 nm is collected by a 0.5 NA lens inside the chamber and imaged onto a CCD camera and a photomultiplier tube (PMT), both with individual ion resolution.

Interaction between the ion and the fiber mode is demonstrated using the electron shelving method¹⁷. The ion is driven on the $5S_{1/2} \leftrightarrow 4D_{5/2}$ transition by 674 nm light from the fiber while being simultaneously illuminated by the 422 nm and 1092 nm beams. Upon shelving

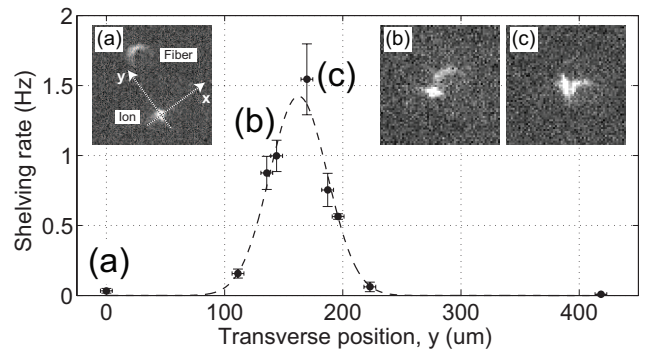


FIG. 3. Measurement of the mode profile of the integrated fiber using the ion as a probe. The dashed line is a fit to a Gaussian profile centered at $163.4 \pm 0.8\ \mu\text{m}$, where the transverse axis has been calibrated by an independent measurement of the fiber mode size at the ion height. Images show the relative position of a single ion and an unfocused image of the fiber.

to the $4D_{5/2}$ state, no 422 nm photons are scattered and the ion remains dark until it decays spontaneously back to the $5S_{1/2}$ state, as illustrated by the single-ion telegraph in the inset of Fig. 2. An effective shelving rate can be quantified by counting the bright-to-dark transitions per total bright time. In Fig. 2, the linear relationship between shelving rate and 674 nm power coupled to the fiber is shown, as expected for a weak driving field.

Because of the exponential fall-off in intensity along the transverse plane of a Gaussian mode, a method for *in situ* control of the ion positioning is highly desired. While DC potentials may achieve ion translation, the resultant displacement of the ion from the RF node incurs additional micromotion that broadens atomic transitions¹⁸, which significantly limits the range and usefulness of DC translation. In contrast, micromotion-free translation can be achieved by shifting the quadrupole field node itself, as has been demonstrated recently^{8,11,14}, by using multiple RF-voltages applied to different electrodes of the trap.

We utilize multiple RF sources to achieve micromotion-free translation of the ion in the horizontal plane of a surface-electrode ion trap. Fig. 3 shows the change in shelving rate as the ion is translated along the y -axis, across the mode of the fiber. The dashed line represents a Gaussian beam shape indicating good qualitative agreement with the shelving rate profile. The beam waist at the ion height of $670\ \mu\text{m}$ has been measured independently using an identical fiber to be $50\ \mu\text{m}$, which is used to calibrate the y -axis in Fig. 3. In units of the measured mode waist, the ion is brought to within 0.13 ± 0.10 of the mode center, despite an initial displacement of 3.34 ± 0.10 arising from trap construction. CCD images show the ion displaced relative to the (unfocused) image of the fiber. In all measurements, the ion was positioned at the RF node by eliminating micromotion amplitude according to the correlation measurement technique¹⁸.

The ultimate precision of RF translation is limited by

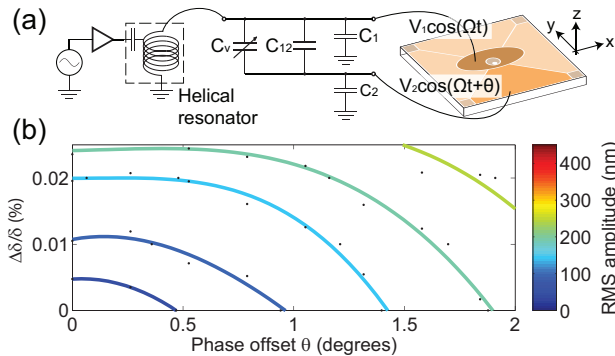


FIG. 4. (Color online) (a) A circuit model for implementation of two in-phase RF drives through a capacitive network. Variable capacitor C_v is used to adjust the RF ratio $\delta = V_2/V_1$. (b) Results of a Monte Carlo simulation showing the RMS amplitudes of classical ion trajectories under nonideal RF control ($\Delta\delta/\delta, \theta$) at the operational point (c) of Fig. 3. Contour lines indicate steps of 50 nm.

the stability and control of the relative amplitudes and phases between the multiple sources. The position uncertainty indicated in Fig. 3 is limited by the resolution of our imaging system to $\pm 5 \mu\text{m}$ and is not fundamental to the RF node translation method. Fig. 4(a) shows our implementation for achieving two in-phase RF voltages through a passive network. Capacitances $C_1, C_2 \approx 30 \text{ pF}$ are intrinsic to the trap electrodes and cryostat wiring, as is $C_{12} \approx 3 \text{ pF}$, which accounts for the intrinsic capacitive coupling between the two electrodes. We introduce a mechanically tunable capacitor $C_v = 0.5 - 30 \text{ pF}$ (Voltronics Corp.) in order to adjust the RF ratio $\delta = V_2/V_1$. Fig. 4(b) is the results of a Monte Carlo simulation at the operational point (c) of Fig. 3, showing RMS amplitudes of classical ion trajectories in steps of 50 nm under RF ratio ($\Delta\delta/\delta$) and phase (θ) imperfections. Given a typical temperature coefficient of 50 ppm/ $^\circ\text{C}$ for C_v , we expect a ratio imprecision of $\Delta\delta/\delta = 0.005\%/^\circ\text{C}$, while phase error θ arises from differential resistances of the two wire paths at a negligible 0.06° per differential ohm. With a 1°C control in capacitor temperature, we conclude that the current implementation achieves $\sim 50 \text{ nm}$ RMS positioning precision. Furthermore, the sensitivity to RF imperfections is trap-design dependent, and may be reduced at the cost of total translational range.

With the ion centered in the fiber mode, we have looked for effects of dielectric charging by the 674 nm fiber light³. In these tests, $125 \mu\text{W}$ of 674 nm light is coupled into the fiber while the amplitude of ion micromotion is recorded for several minutes to detect any dynamic shifts in the ion position due to a possible fiber-induced generation of charge. We observe induced fields of $\sim 10 \text{ V/m}$ by the fiber, with charging and discharging time constants of $1.6 \pm 0.3 \text{ s}$ and $4.7 \pm 0.6 \text{ s}$. Following the initial charge generation, the micromotion amplitude remains constant for minutes, indicating stable saturation of fiber-induced charge.

In conclusion, we have demonstrated an ion trap with an integrated SM fiber for light delivery, and an *in situ* micromotion-free optimization of the ion-fiber spatial overlap. The fiber has been used to directly address the qubit transition of a single ion in the trap and, as such, the fiber-trap system represents a step towards optics-integration for large-scale QIP in surface-electrode designs. Moreover, our assembly is compatible with more advanced fiber systems, such as lensed fibers to achieve higher field intensities, or photonic crystal fibers that propagate all relevant lasers through a single integrated port. In a cryogenic environment, such an all-inclusive port may eliminate the requirement of free-space optical access, greatly reducing the heatload and enabling sub-Kelvin trap operation. An integrated trap that utilizes the fiber facet as one of the mirrors of an optical cavity could serve as a node in a distributed QIP architecture where the photon state can be extracted through the fiber¹.

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- ¹J. I. Cirac, P. Zoller, H. J. Kimble, and H. Mabuchi, *Physical Review Letters* **78**, 3221 (1997).
- ²J. Kim and C. Kim, *Quantum Information & Computation* **9**, 0181 (2009).
- ³M. Harlander, M. Brownnutt, W. Hansel, and R. Blatt, *New Journal of Physics* **12**, 093035 (2010).
- ⁴G. R. Guthohrlein, M. Keller, K. Hayasaka, W. Lange, and H. Walther, *Nature* **414**, 49 (2001).
- ⁵P. F. Herskind, A. Dantan, J. P. Marler, M. Albert, and M. Drewsen, *Nature Physics* **5**, 494 (2009).
- ⁶G. Shu, N. Kurz, M. Dietrich, and B. B. Blinov, *Phys. Rev. A* **81**, 042321 (2010).
- ⁷E. W. Streed, B. Norton, A. Jechow, T. J. Weinhold, and D. Kielpinski, *Phys. Rev. Lett.* **106**, 010502 (2011).
- ⁸A. P. VanDevender, Y. Colombe, J. Amini, D. Leibfried, and D. J. Wineland, *Physical Review Letters* **105**, 023001 (2010).
- ⁹P. F. Herskind, S. X. Wang, M. Shi, Y. Ge, M. Cetina, and I. L. Chuang, arXiv:1011.5259v1 (2010).
- ¹⁰C. Schneider, M. Enderlein, T. Huber, and T. Schaeetz, *Nature Photonics* **4**, 772 (2010).
- ¹¹P. F. Herskind, A. Dantan, M. Albert, J. P. Marler, and M. Drewsen, *Journal Of Physics B* **42**, 154008 (2009).
- ¹²R. Blatt and D. J. Wineland, *Nature* **453**, 1008 (2008).
- ¹³H. Margolis, G. Barwood, G. Huang, K. H. A., S. Lea, K. Szymaniec, and P. Gill, *Science* **306**, 1355 (2004).
- ¹⁴T. H. Kim, P. F. Herskind, T. Kim, J. Kim, and I. L. Chuang, *Phys. Rev. A* **82**, 043412 (2010).
- ¹⁵P. B. Antohi, D. Schuster, G. M. Akselrod, J. Labaziewicz, Y. Ge, Z. Lin, W. S. Bakr, and I. L. Chuang, *Rev. Sci. Instrum.* **80**, 013103 (2009).
- ¹⁶M. Brownnutt, V. Letchumanan, G. Wilpers, R. C. Thompson, P. Gill, and A. G. Sinclair, *Applied Physics B-Lasers And Optics* **87**, 411 (2007).
- ¹⁷H. Dehmelt, *Bulletin of the American Physical Society* **20**, 60 (1975).
- ¹⁸D. J. Berkeland, J. D. Miller, J. C. Bergquist, W. M. Itano, and D. J. Wineland, *Journal Of Applied Physics* **83**, 5025 (1998).